Applied for a patent

# The Features of TPS method (our original surface treatment technology under a vacuum)

- It can be treated without contamination under a vacuum.
- It is not a surface modification. Because the roughness of film surface is not changed.
- TPS can be materialized over 10.0 [N/cm] adhesive strength between Polyimide film and Copper by sputtering layer.

## The comparison data of adhesive strength with TPS treated and untreated Polyimide films by sputtering Copper.

Xa method of measurement of Adhesive strength is by a peel test machine. XThe value of surface resistance before and after TPS means a change of film surface roughness.

Yellowish Polyimide film (thickness: 2 0 $\mu$ m)		
	Adhesive strength[N/ c m]※1	Surface resistance of $Cu[\Omega/sq]$
Untreated PI + Cu	0.10	0.214
TPS treated PI + Cu	11.55	0.412

Kapton film (thickness : 3 0 $\mu$ m)		
	Adhesive strength[N/ c m] $\%$ 1	Surface resistance of $Cu[\Omega/sq]$
Untreated PI+Cu	5.45	0.397
TPS treated PI +Cu	10.90	0.349

#### The condition of peel test

An angle of peel=90°

F=20N Width of test piece:2mm Plating thickness:25 $\!\mu$  m Peel speed:0.5mm/min

(&1)Adhesive strength value is converted into 1cm width.

#### SEM graph of TPS treated polyimide film surface



Notes : All above values are the measurement values and they are not guaranteed performance.



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### SEM graph of no treated polyimide film surface

The surface resistance is measured by 4-terminal method.

(&2) Yellowish polyimide film and Kapton film are supplied

by different manufacturer.

